

Supporting Information for

Facile and selective synthesis of zeolites L and W from a single-source heptanuclear aluminosilicate precursor

*Akira Imaizumi,^a Akinobu Nakada,^a Takeshi Matsumoto,^b and Ho-Chol Chang^{a, *}*

^a Department of Applied Chemistry, Faculty of Science and Engineering, Chuo University,
1-13-27 Kasuga, Bunkyo-ku, Tokyo 112-8551, Japan.

^b Precursory Research for Embryonic Science and Technology (PRESTO), Japan Science and
Technology Agency (JST), 4-1-8 Honcho, Kawaguchi, Saitama 332-0012, Japan.

* To whom correspondence should be addressed. E-mail: chang@kc.chuo-u.ac.jp

Phone: +81-3-3817-1897. Fax: +81-3-3817-1895.

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25. **References**

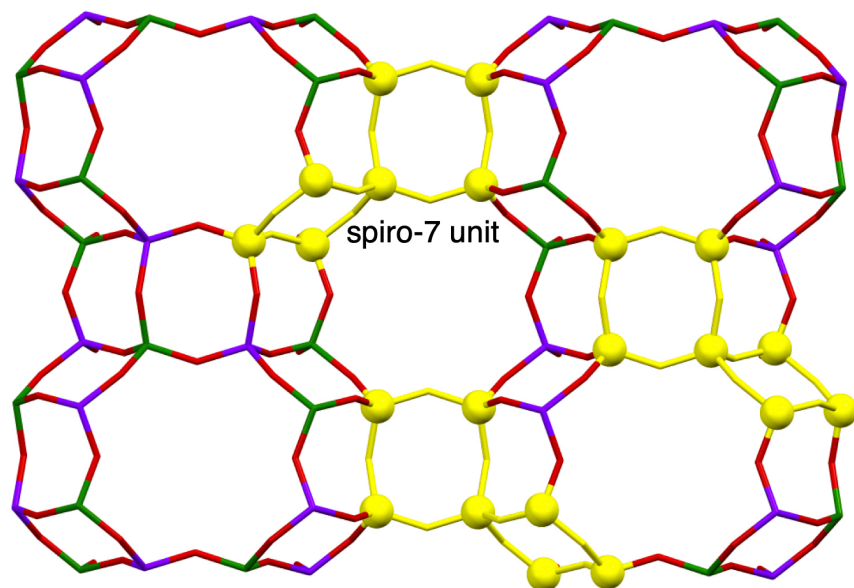


Fig. S1 Spiro-7 unit (yellow) in the MER-type structure. Color code: red = O; purple = Al; green = Si. The Si/Al ratio of the structure equals 1, and K^+ ions are omitted for clarity.

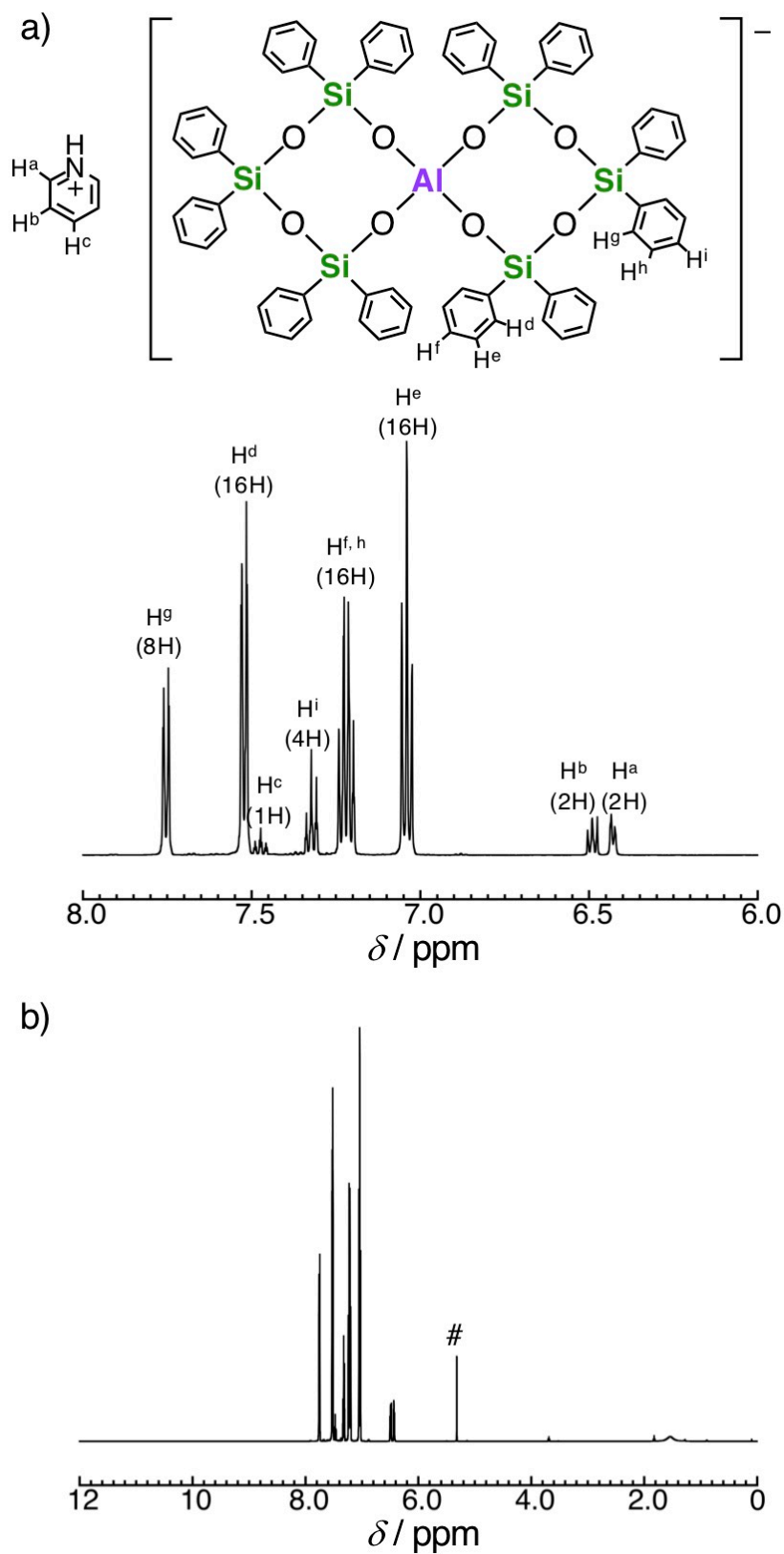


Fig. S2 a) Aromatic region and b) full range of the ^1H NMR (500 MHz, CD_2Cl_2) spectra of AlSi_6 . A symbol “#” denotes the residual proton of dichloromethane.

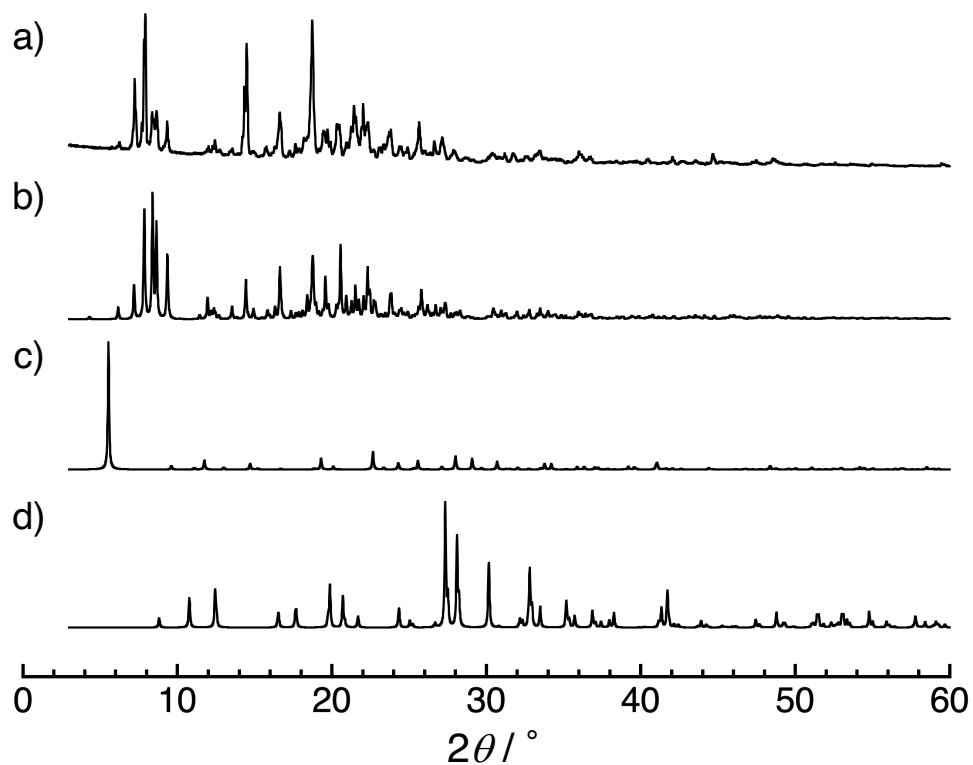


Fig. S3 PXRD pattern of a) the synthesized AlSi_6 and the simulated patterns for b) AlSi_6 , c) zeolite L^{S1} , and d) W^{S2}

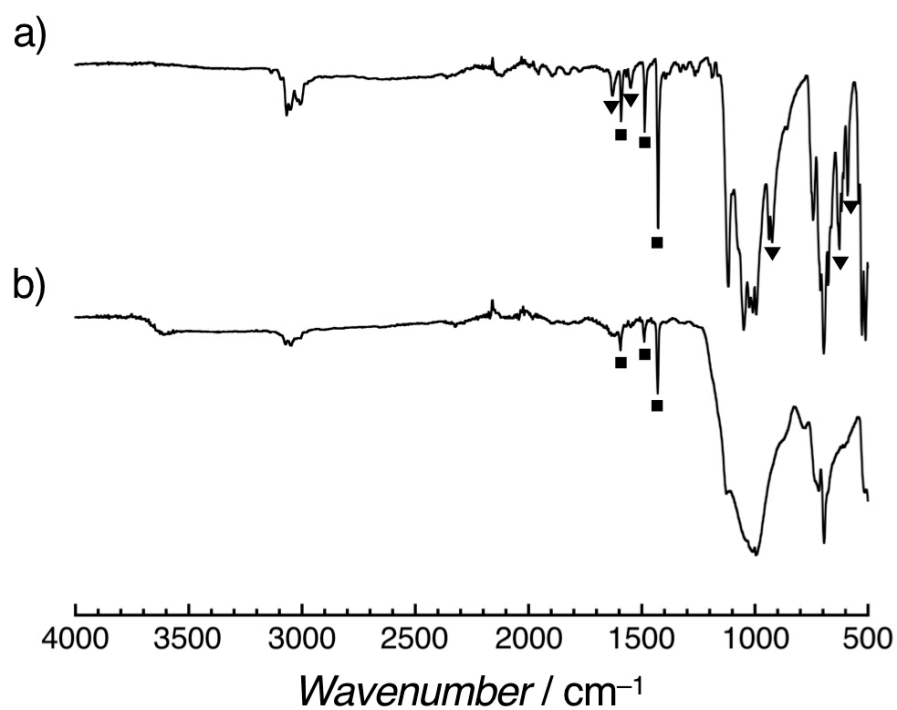


Fig. S4 IR spectra of a) AlSi₆ and b) the samples obtained from TG measurements at 180 °C. The symbols “▼” and “■” mark absorption bands assignable to pyridinium and phenyl group, respectively.

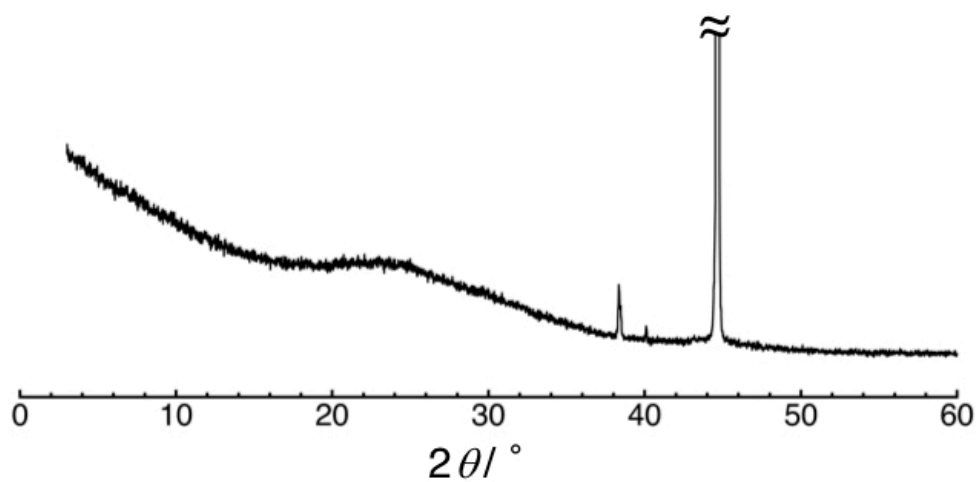


Fig. S5 PXRD pattern of the sample obtained from the heating AlSi_6 to 800 °C under an N_2 atmosphere. The diffractions peaks at 38.3, 40.1, and 44.6° are originated from the Al pan used as a sample holder.

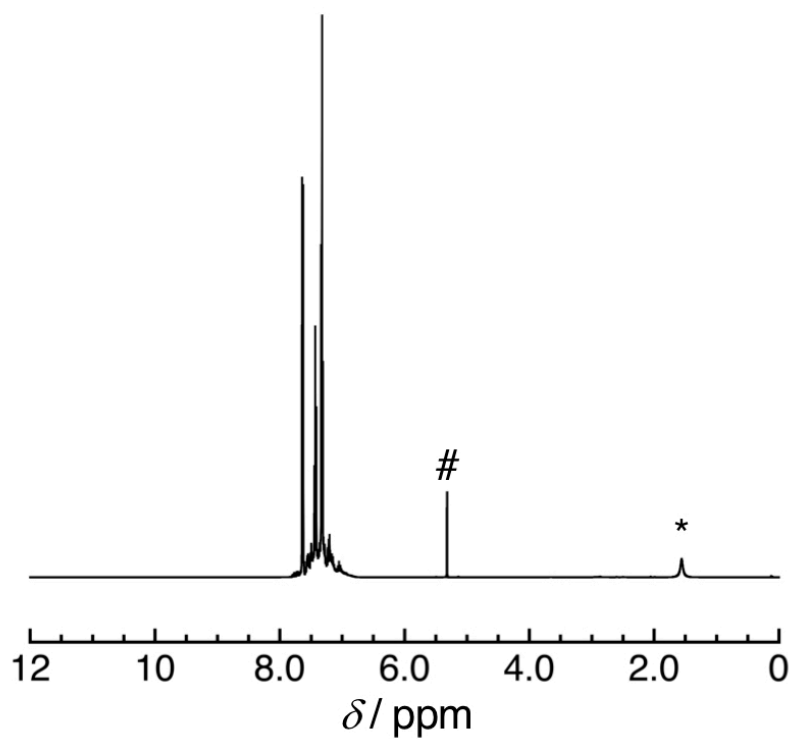


Fig. S6 ^1H NMR (500 MHz, CD_2Cl_2) spectrum of the product in the solution phase obtained from refluxing AlSi_6 in aqueous HCl (12 eq.) for 12 h. The symbols “#” and “*” denote the residual proton of dichloromethane and protons of Si-OH and/or H_2O , respectively.

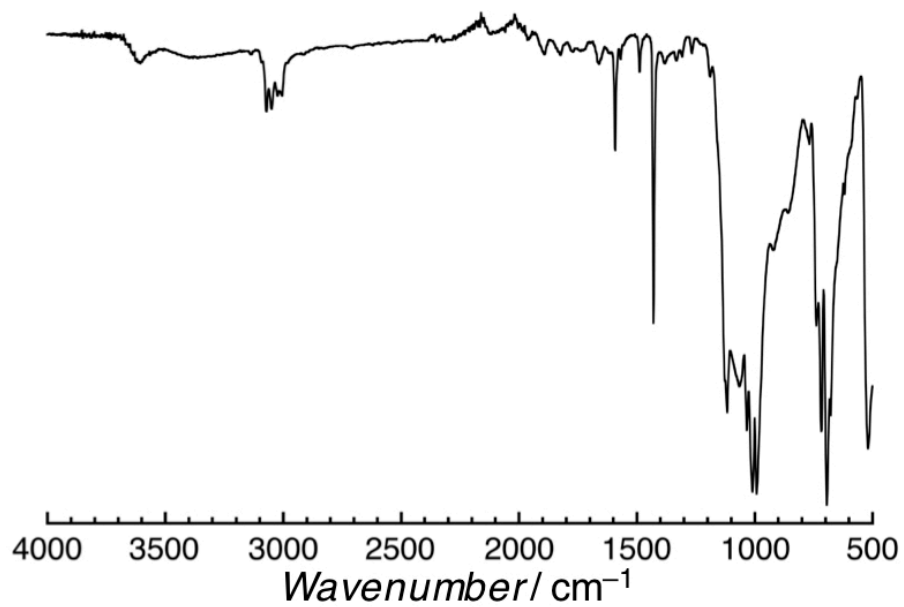


Fig. S7 IR spectrum of the products in the solution phase obtained from the hydrothermal treatment of AlSi_6 at 150 °C for 12 h in the presence of HCl (12 eq.).

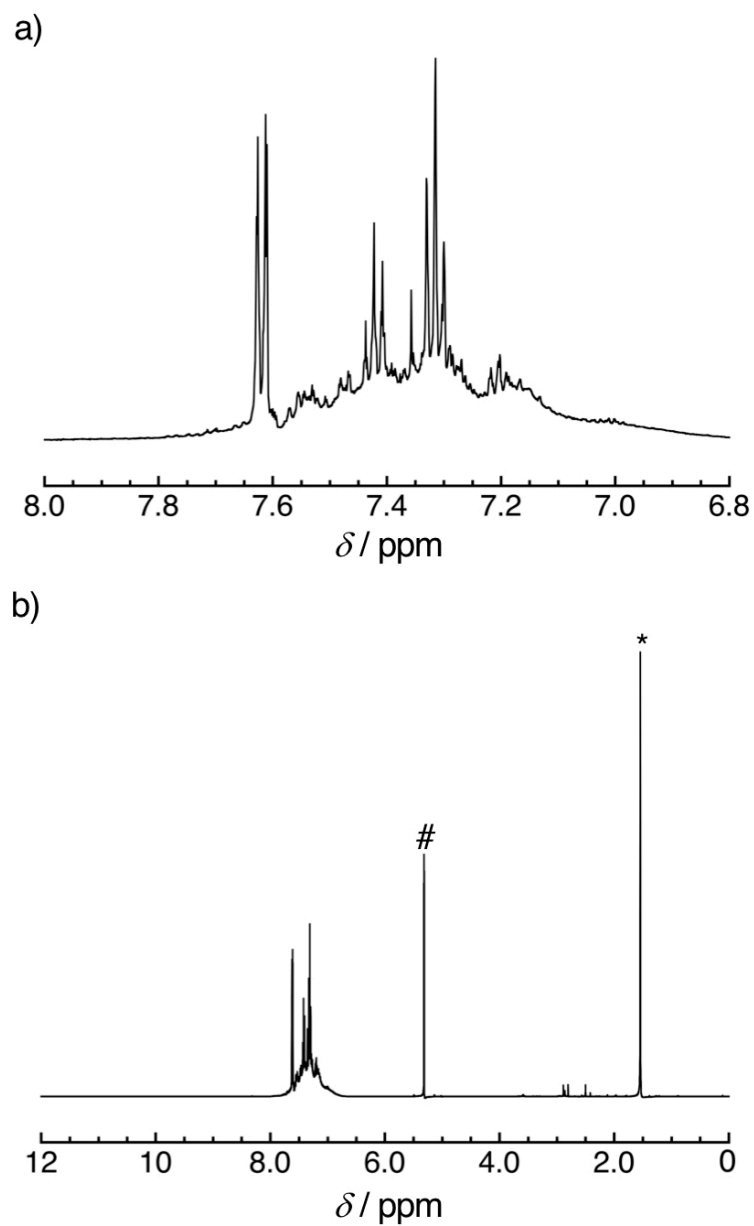


Fig. S8 a) Aromatic region and b) full range of the ^1H NMR (500 MHz, CD_2Cl_2) spectrum of the product in the solution phase obtained from the hydrothermal treatment of AlSi_6 at 150 °C for 12 h in aqueous HCl (12 eq.). The symbol # denote the residual proton of dichloromethane and protons, and the signal * denotes Si-OH and/or H_2O .

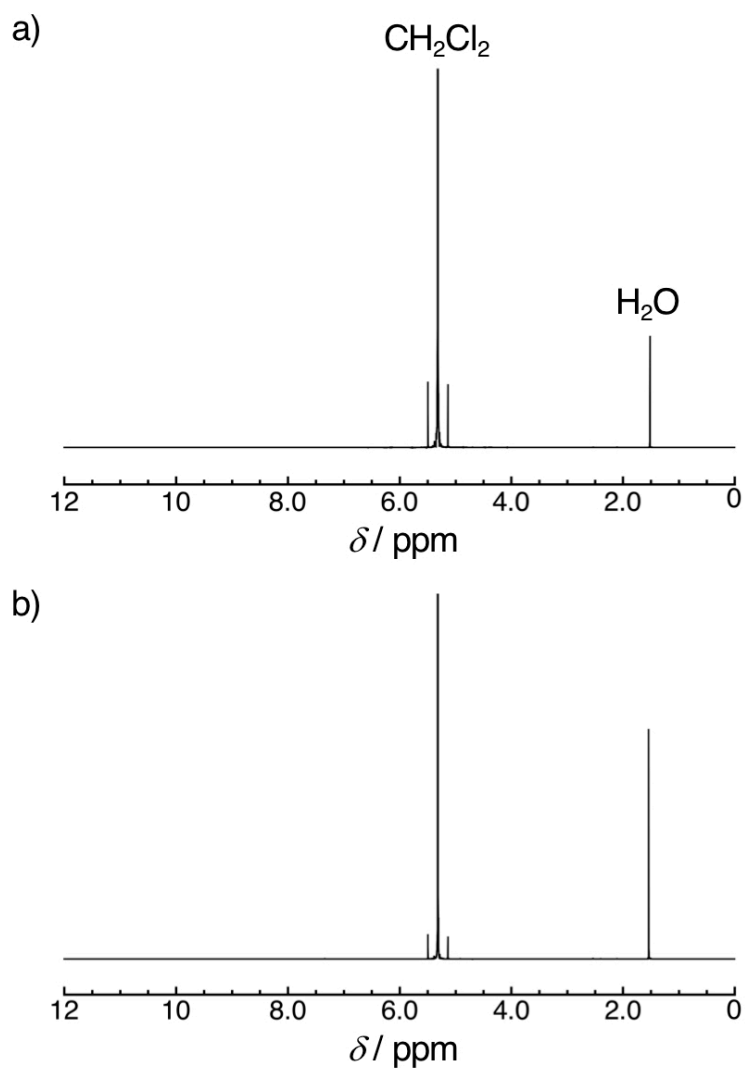


Fig. S9 ^1H NMR spectra (500 MHz, CD_2Cl_2) of the products in the solution phase obtained from a) refluxing and b) the hydrothermal treatment of AlSi_6 at 150 °C for 12 h in the presence of HCl (12 eq.).

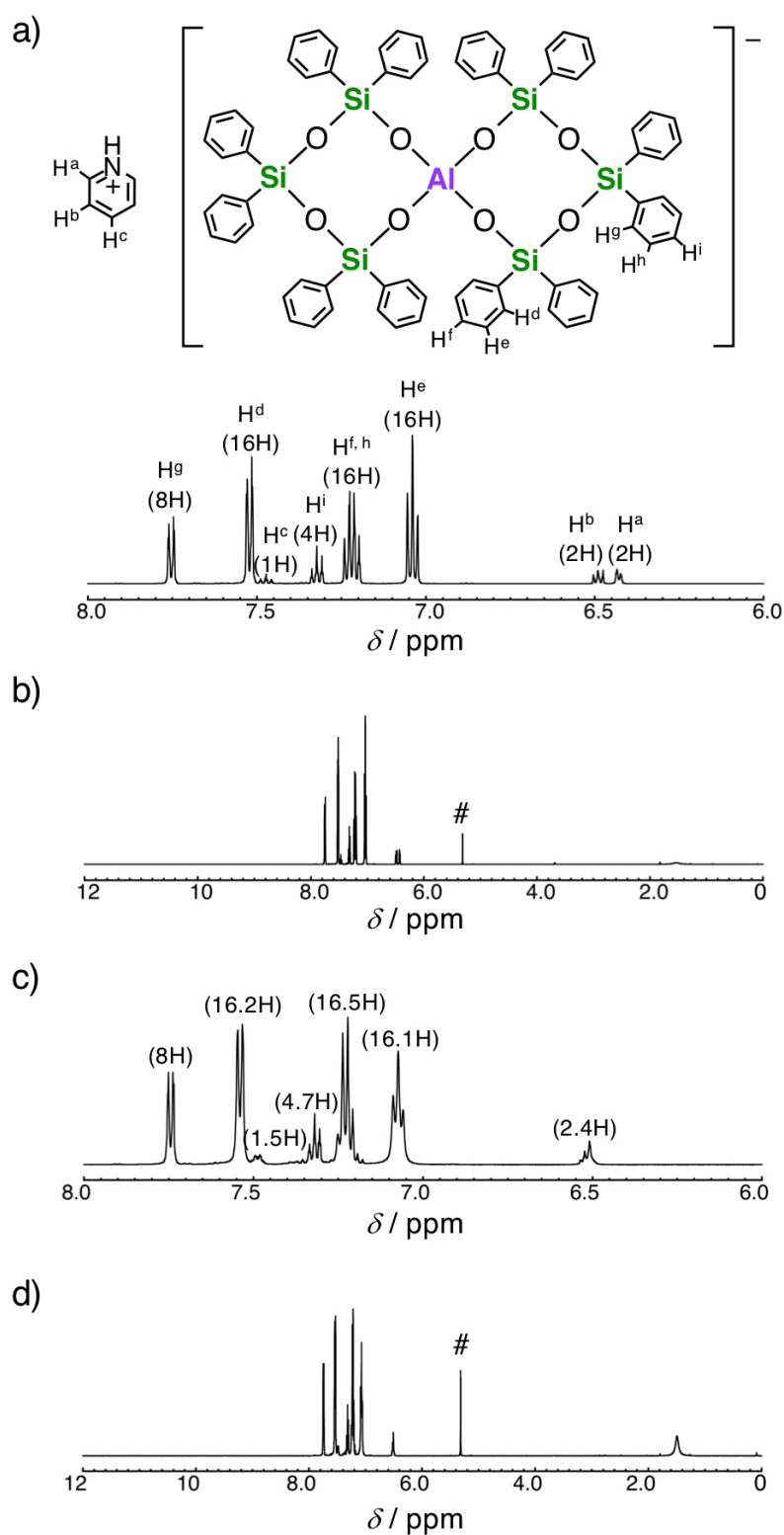


Fig. S10 Aromatic region and full range of the ^1H NMR spectra (500 MHz, CD_2Cl_2) of a, b) AlSi_6 and c, d) the soluble products obtained from the refluxing of AlSi_6 for 12 h in aqueous KOH (12 eq.). The symbol “#” denotes the residual proton of dichloromethane.

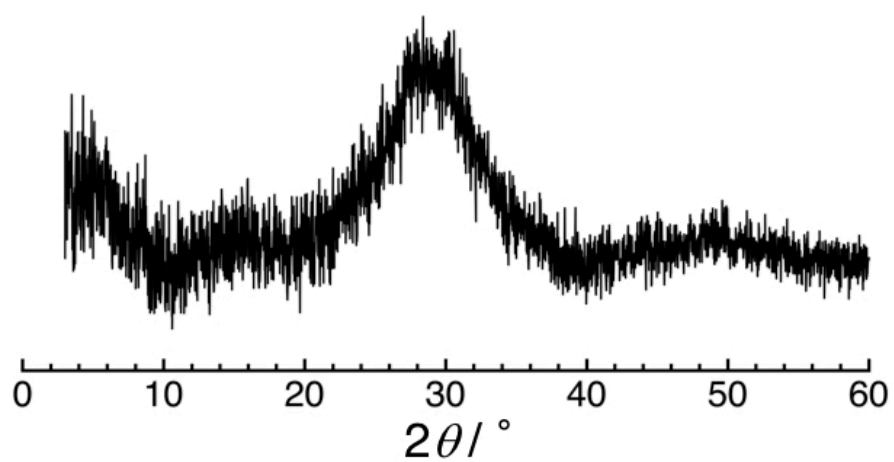


Fig. S11 PXRD pattern of the product obtained from the refluxing of AlSi_6 in aqueous KOH (12 eq.) for 12 h.

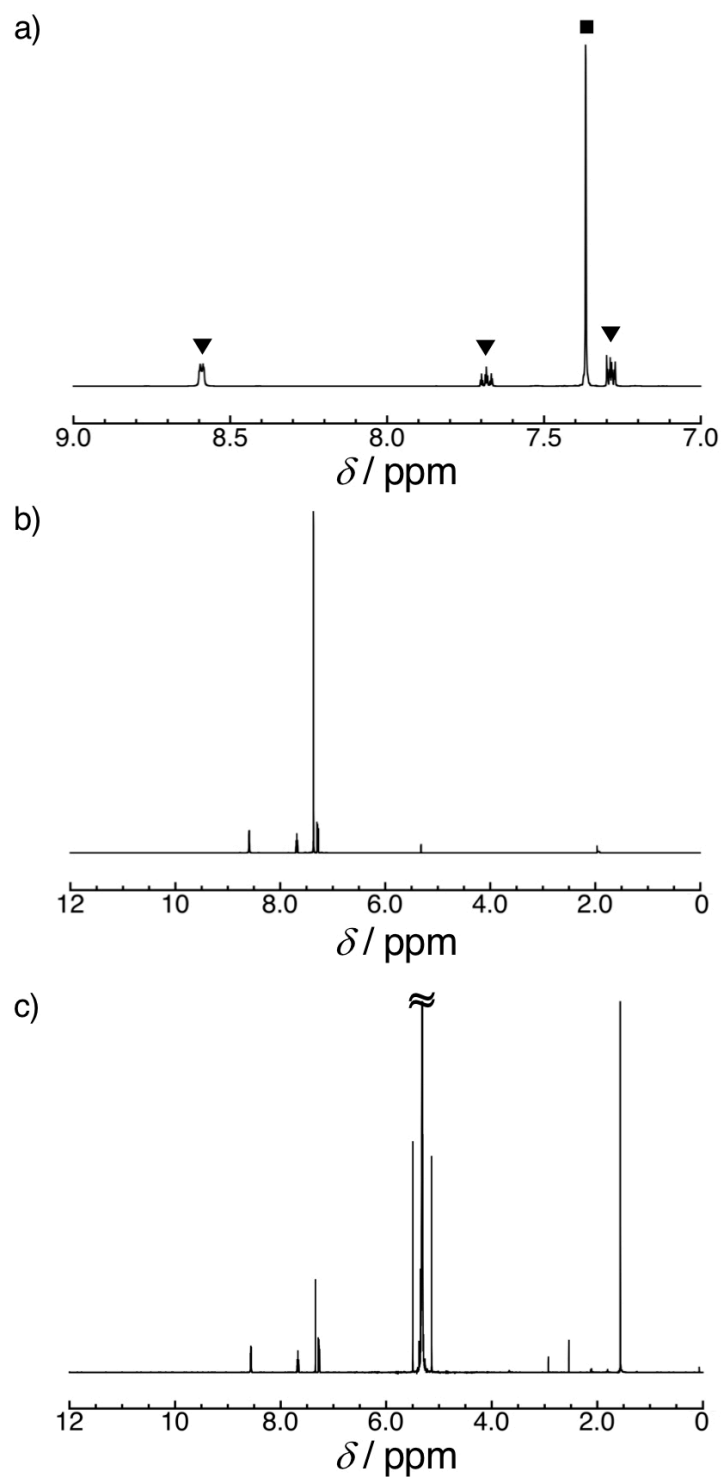


Fig. S12 a) Aromatic region and b) full range of the ^1H NMR (500 MHz, CD_2Cl_2) spectrum of a mixture of pyridine and benzene for reference, and c) full range spectrum of the soluble product in CD_2Cl_2 obtained from hydrothermal treatment of AlSi_6 in the presence of KOH (12 eq.) at 150 °C for 12 h. The symbols ▼ and ■ denote signals from pyridine and benzene, respectively.

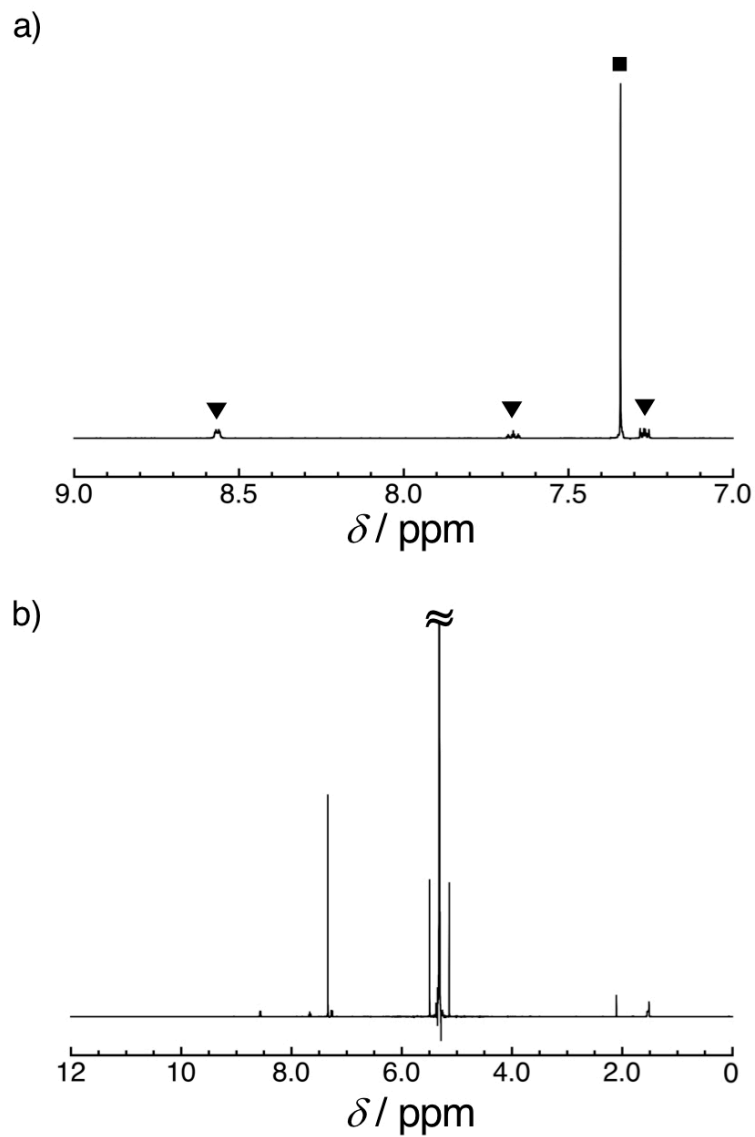


Fig. S13 a) Aromatic region and b) full range of the ¹H NMR (500 MHz) spectrum of the soluble product in CD₂Cl₂ obtained from the hydrothermal treatment of AlSi₆ in the presence of KOH (12 eq.) at 160 °C for 12 h. The symbols ▼ and ■ denote signals from pyridine and benzene, respectively.

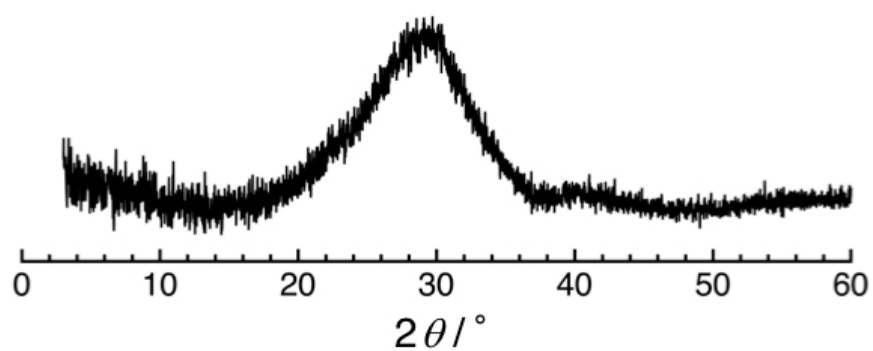


Fig. S14 PXRD pattern of the amorphous solid obtained from the hydrothermal treatment of AlSi_6 in the presence of KOH (24 eq.) at 160°C .

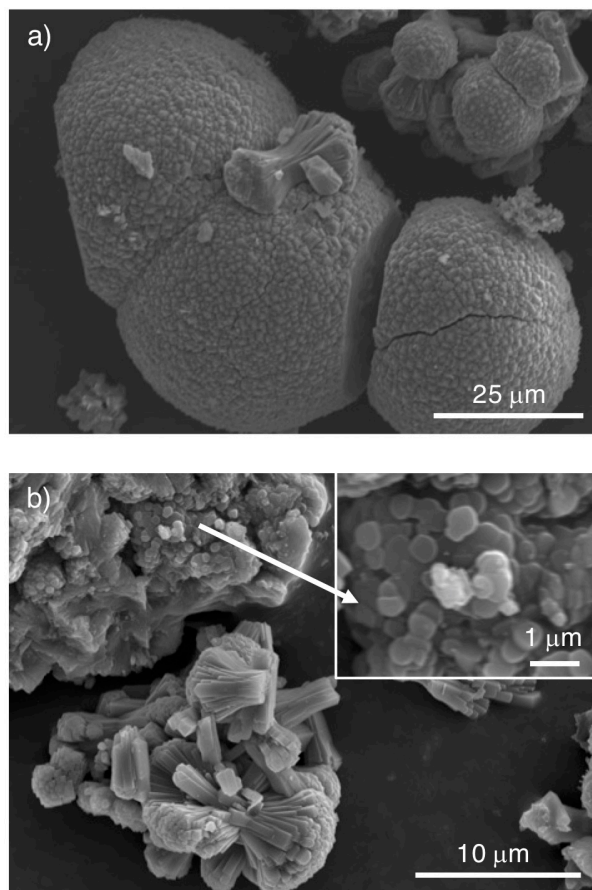


Fig. S15 SEM images of a) zeolite W and b) a mixture of zeolite W and L obtained from the hydrothermal treatment of AlSi_6 in the presence of KOH (x eq.) at 160 °C (a) $x = 9$ and b) $x = 6$. Inset in b) shows closed up image of disk-shaped crystals of zeolite L.

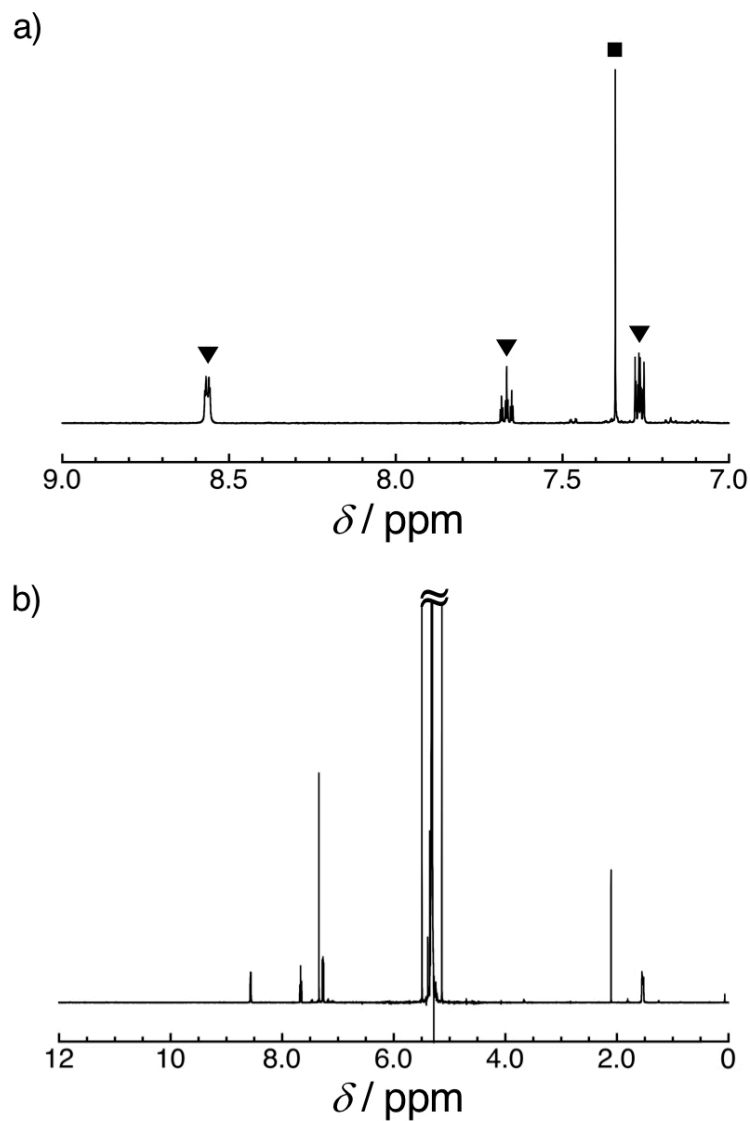


Fig. S16 a) Aromatic region and b) full range of the ^1H NMR (500 MHz) spectrum of the soluble product in CD_2Cl_2 obtained from the hydrothermal treatment of AlSi_6 in the presence of KOH (3 eq.) at 160 °C for 12 h. The symbols ▼ and ■ denote signals from pyridine and benzene, respectively.

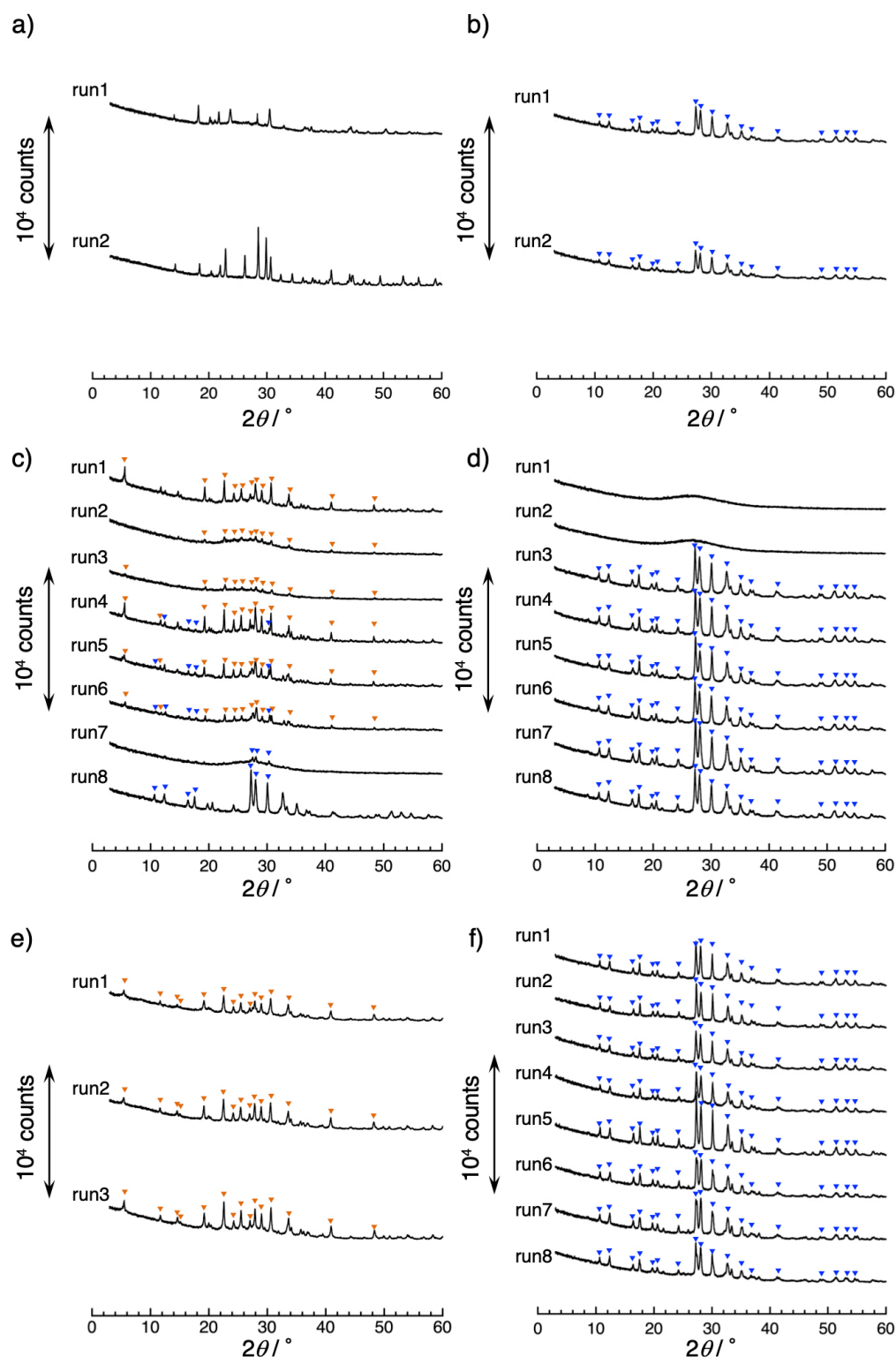


Fig. S17 PXRD patterns of powders synthesized from a) $\text{Al}(\text{OH})_3$, SiO_2 , and 3 eq. KOH; b) $\text{Al}(\text{OH})_3$, SiO_2 , and 12 eq. KOH; c) Al, SiO_2 , and 3 eq. KOH; d) Al, SiO_2 and 12 eq. KOH; e) AlSi_6 and 3 eq. KOH; f) AlSi_6 and 12 eq. KOH. All reactions were carried out for 12 h at 160 °C. All measurements were performed using the following conditions: scan rate = 5 °/min; step = 0.02 °; at room temperature. The symbols “▼” and “▼” indicate peaks derived from zeolites L and W, respectively.

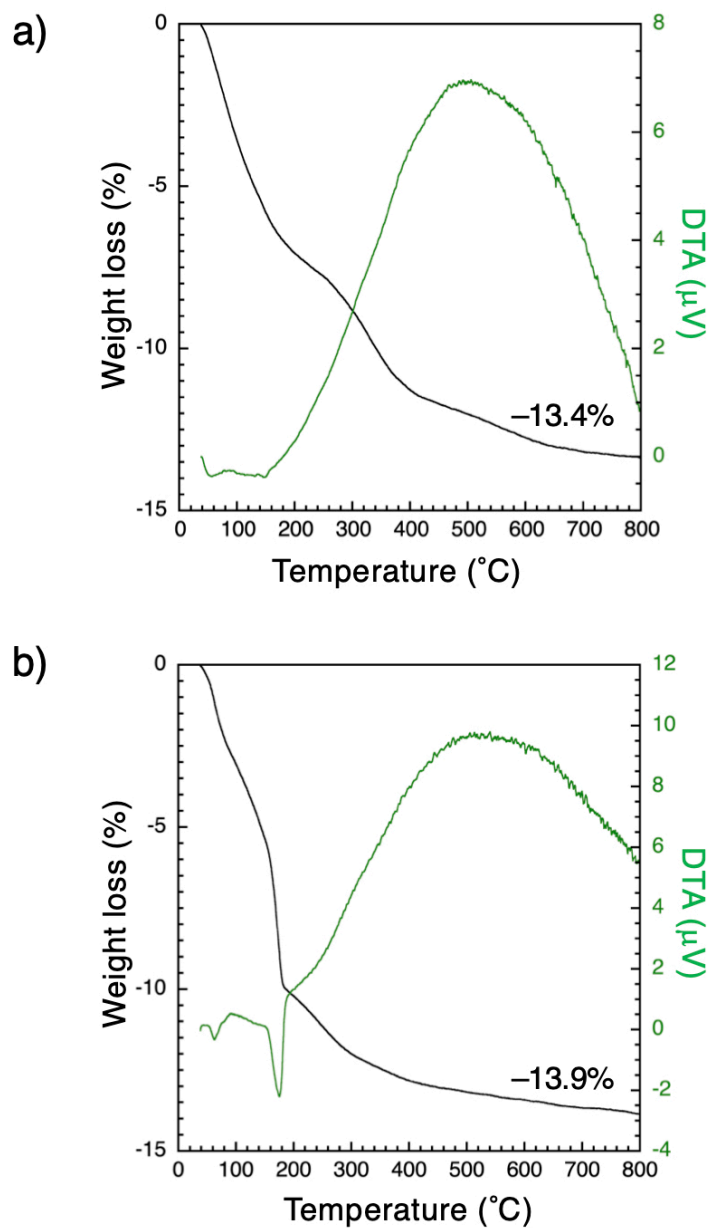


Fig. S18 TG (black line)-DTA (green line) diagrams of a) zeolites L and b) W synthesized from AlSi_6 in the presence of 3 or 12 eq. of KOH at 160 °C for 12 h, respectively.

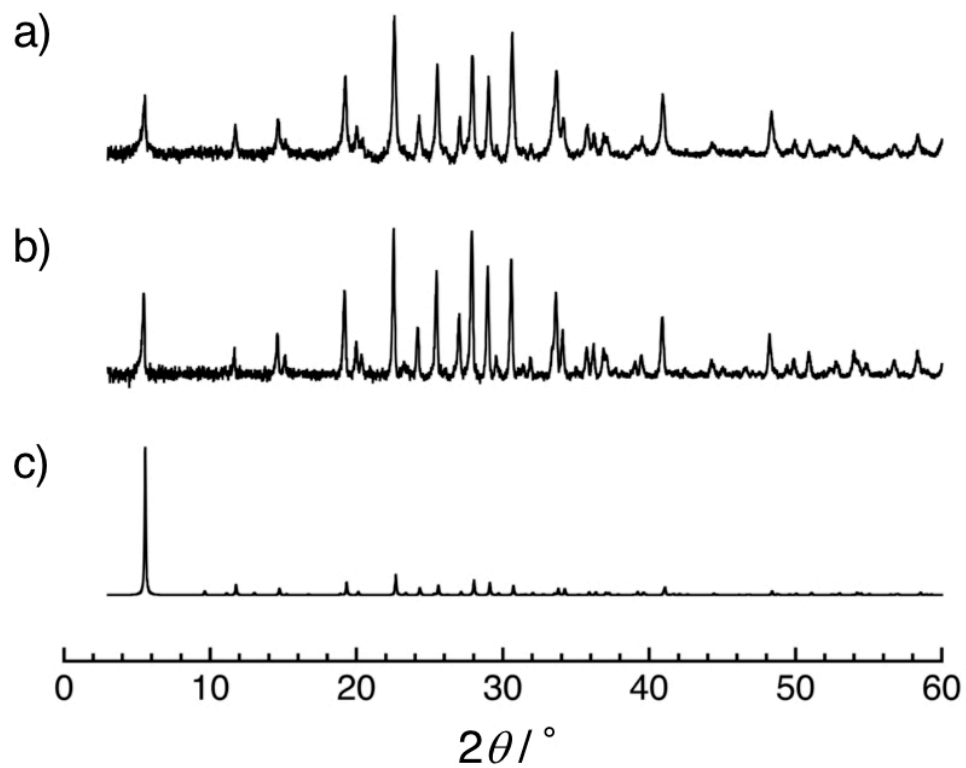


Fig. S19 PXRD patterns of the zeolite L obtained from the hydrothermal treatment of AlSi_6 in the presence of KOH (3 eq.) at a) 180 and b) 200 °C. c) The simulated PXRD pattern of zeolite L.^{S1}

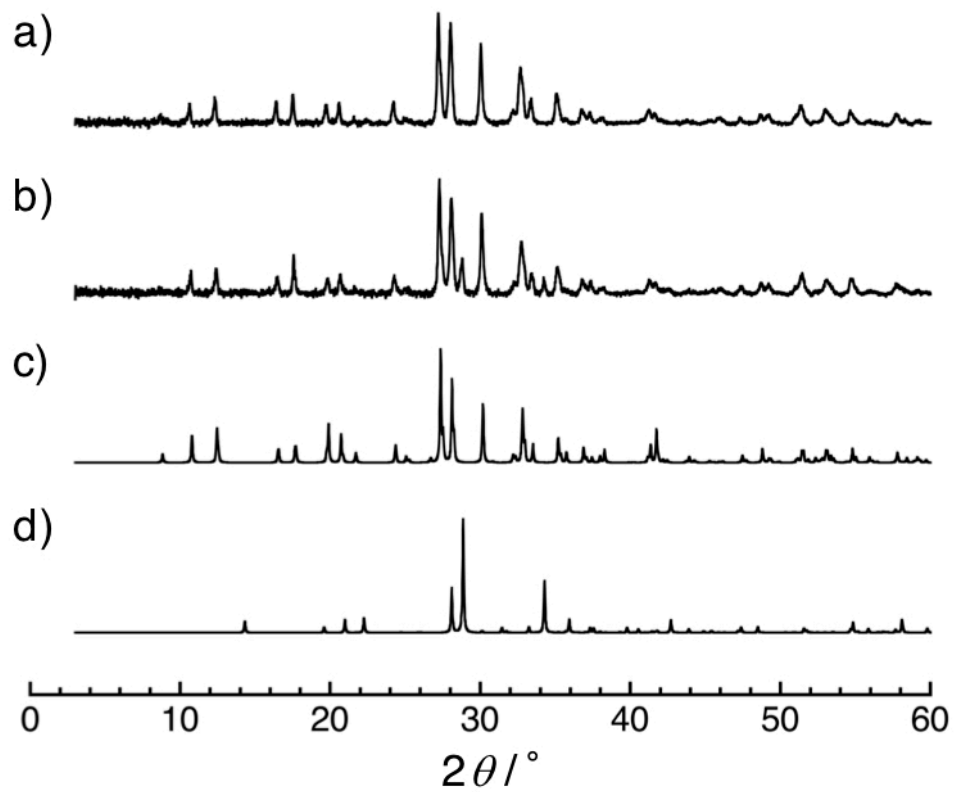


Fig. S20 PXRD patterns of the mixture of zeolite W and megakalsilite obtained from the hydrothermal treatments of AlSi_6 in the presence of KOH (x eq.) at 180 °C (a) $x = 6$ and b) $x = 9$). Simulated PXRD patterns for c) zeolite W^{S2} and d) megakalsilite.^{S3}

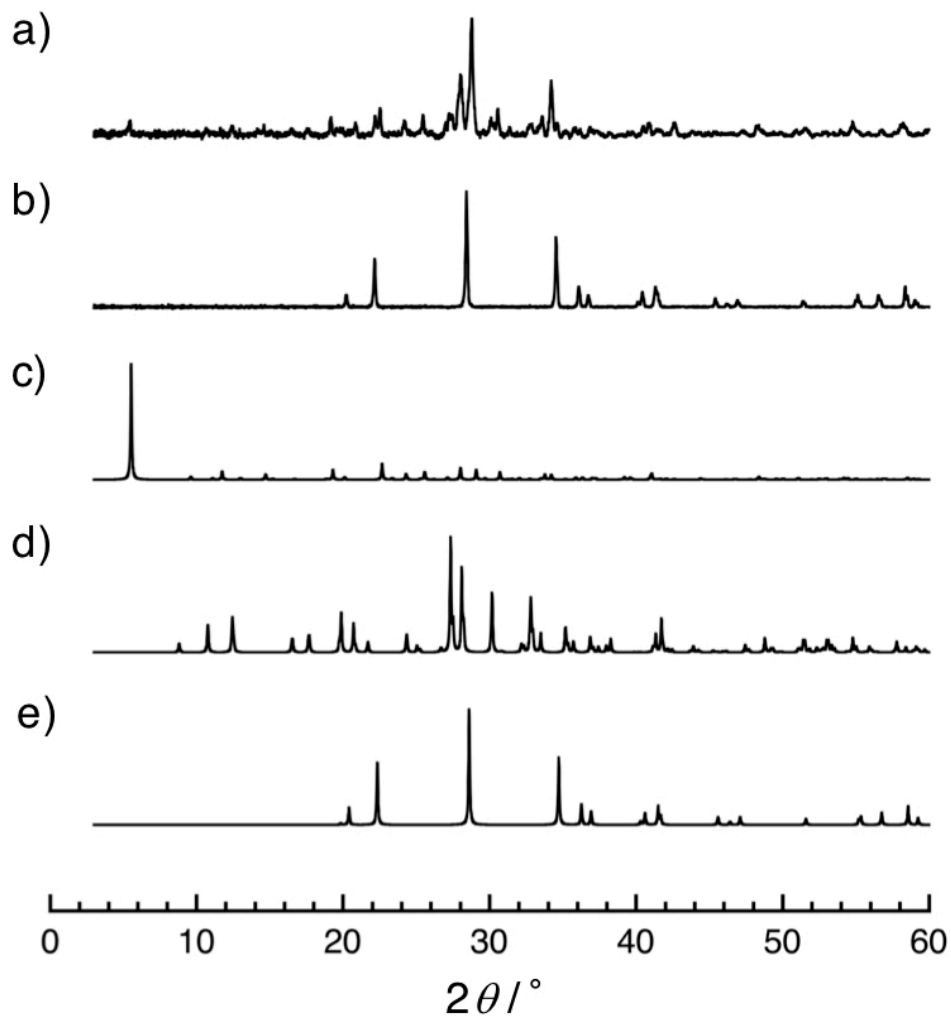


Fig. S21 PXRD patterns of zeolites L, W, and kalsilite obtained from the hydrothermal treatments of AlSi_6 in the presence of KOH (x eq.) at 200 °C (a) $x = 6$ and b) $x = 9$). Simulated PXRD patterns for c) zeolite L,^{S1} d) zeolite W,^{S2} and e) kalsilite.^{S4}

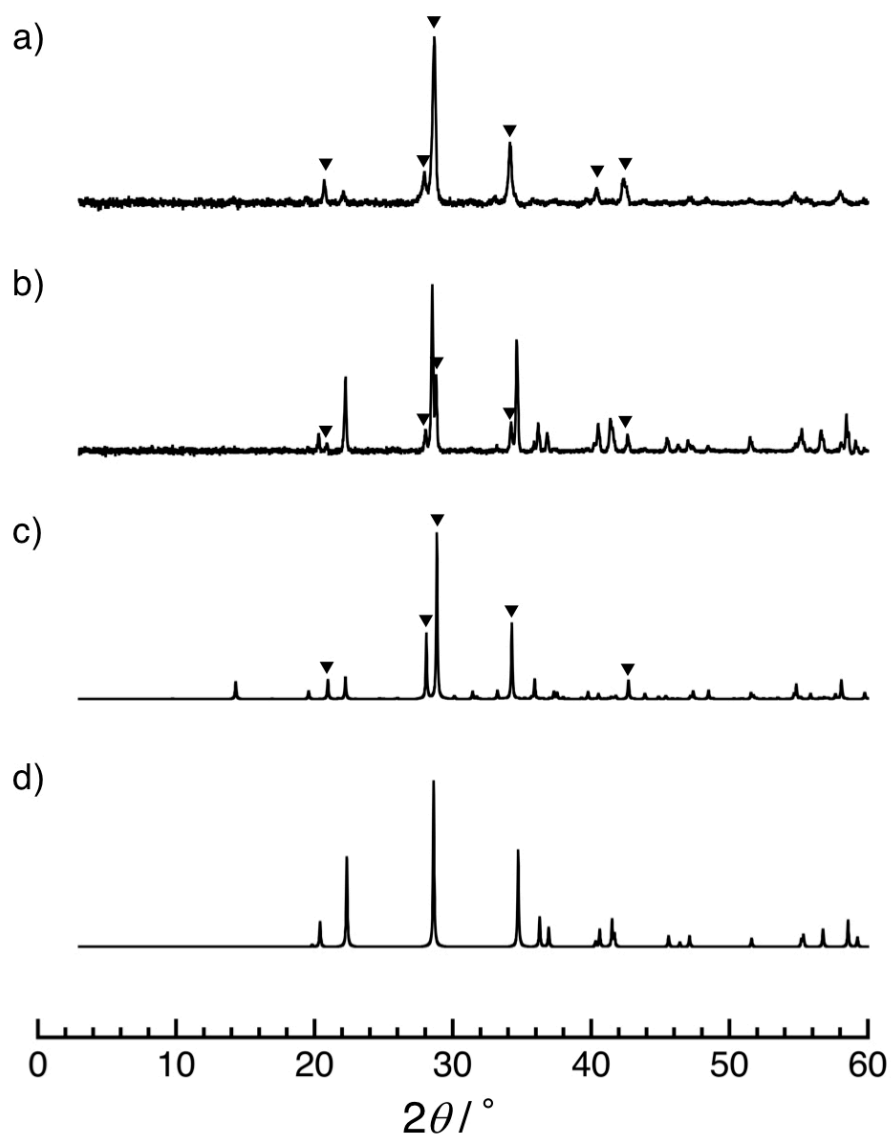


Fig. S22 PXRD patterns of the megakalsilite and kalsilite obtained from the hydrothermal treatment of AlSi_6 in the presence of KOH 12 eq. at a) 180 and b) 200 °C. Simulated PXRD patterns for c) megakalsilite^{S3} and d) kalsilite.^{S4} The signal “▼” denotes characteristic diffraction peaks for megakalsilite.

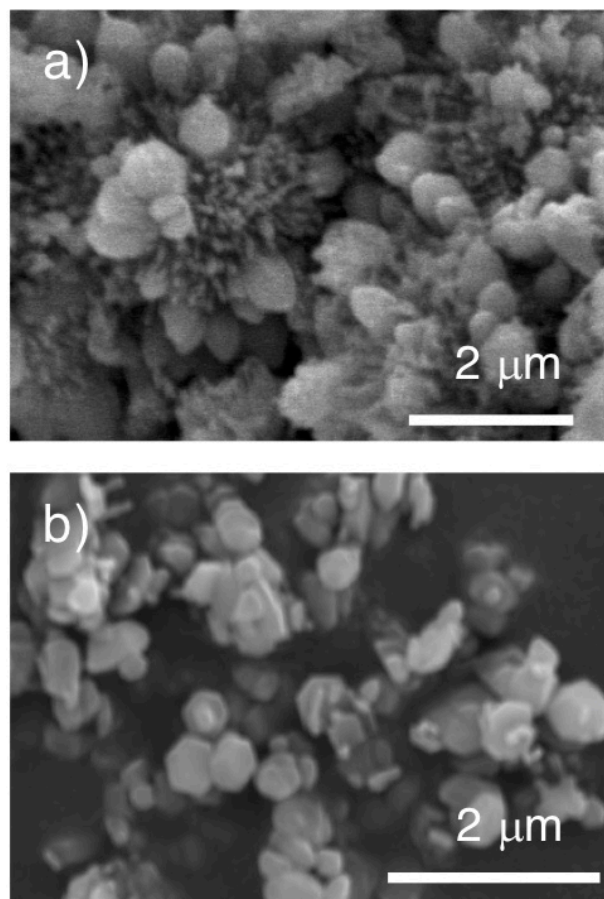


Fig. S23 SEM images of a) kalsilite and b) megakalsilite obtained from the hydrothermal treatments of AlSi_6 in the presence of KOH (12 eq.) at a) 180 and b) 200 °C.

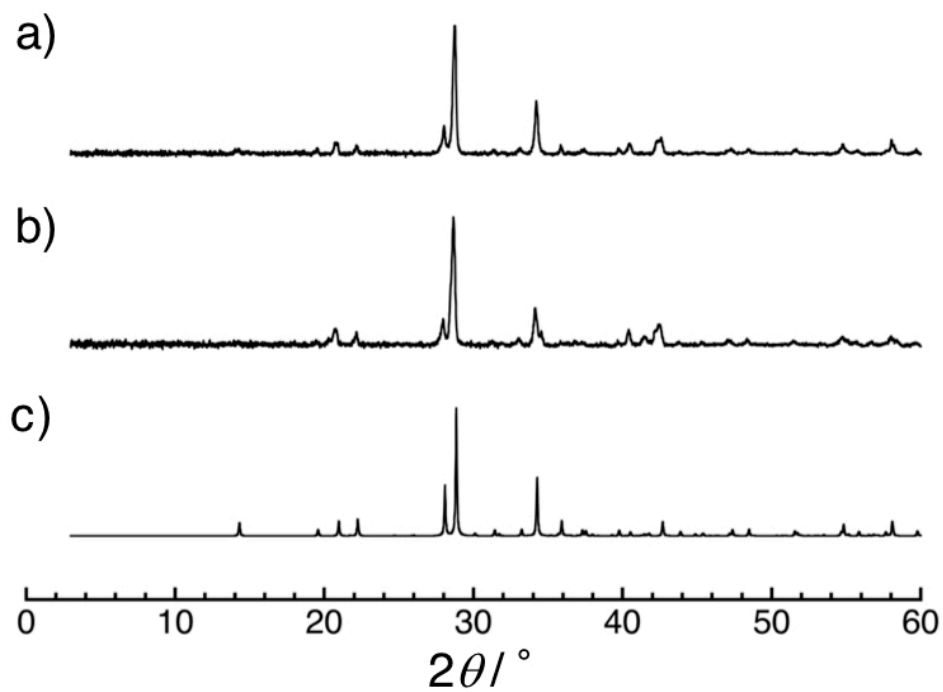


Fig. S24 PXRD patterns of the megakalsilite obtained from the hydrothermal treatments of AlSi_6 in the presence of KOH (24 eq.) at a) 180 and b) 200 °C. c) Simulated PXRD patterns for megakalsilite.^{S3}

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